

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of :
Hiroto YUKAWA et al. :
Serial No. NEW : **Attn: APPLICATION BRANCH**
Filed July 31, 2003 : Attorney Docket No. 2003-1079

**POSITIVE-WORKING CHEMICAL-
AMPLIFICATION PHOTORESIST
COMPOSITION
(Rule 1.53(b) Divisional
of Serial No. 10/126,673,
Filed April 22, 2002)**

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

In the interest of compact prosecution, please amend the present application as follows: